

技术及应用

## 星用功率MOSFET器件单粒子烧毁试验研究

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**摘要** 针对国产功率MOSFET器件JTMCS081和JTMCS062, 利用实验室的MOSFET器件单粒子烧毁试验测试系统, 在<sup>252</sup>Cf模拟系统上开展了单粒子烧毁评估试验研究。通过试验研究获得了被试器件单粒子烧毁的电压阈值, 为被测器件在卫星型号的使用提供技术参考依据。

**关键词** 功率MOSFET器件; 单粒子烧毁; 铜源

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## Single-Event Burnout of Power MOSFET Devices for Satellite Application

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**Abstract** Single-event burnout (SEB) sensitivity was tested for power MOSFET devices, JTMCS081 and JTMCS062, which were made in Institute of Microelectronics, Chinese Academy of Sciences, using californium-252 simulation source. SEB voltage threshold was found for devices under test (DUT). It is helpful for engineers to choose devices used in satellites.

**Key words** [power MOSFET device](#) [single-event burnout \(SEB\)](#) [californium-252 source](#)

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